Ab initio atomistic thermodynamics

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Why thermodynamics for materials?

Thermodynamics determines defect concentrations and phase transformations, and influences magnetic properties, surface reactions, and crystal growth (the latter two are controlled by *kinetics*)

There is always a particle exchange between the material and its environment at finite *T*

Example

Consider a metal surface in an oxygen atmosphere



Adsorption will take place until the equilibrium is reached

Example

Consider a metal surface in an oxygen atmosphere

The point of equilibrium depends on temperature, pressure, volume, ...



Thermodynamic potentials

Internal energy $U(S, V, \{N\})$ Enthalpy $H(S, p, \{N\}) = U + pV$ Helmholtz free energy $F(T, V, \{N\}) = U - TS$ Gibbs free energy $G(T, p, \{N\}) = U - TS + pV$ Energy balance equation

$$dU = TdS - pdV + \sum_{i} \mu_{i} dN_{i}$$

with chemical potentials

$$\mu_{i} = \left(\frac{\partial U}{\partial N_{i}}\right)_{S,V} = \left(\frac{\partial H}{\partial N_{i}}\right)_{S,p} = \left(\frac{\partial F}{\partial N_{i}}\right)_{T,V} = \left(\frac{\partial G}{\partial N_{i}}\right)_{T,p}$$

Reaching the equilibrium

- At constant T a system minimizes its free energy (-TS), not the internal energy U
- If also volume V is constant, the energy minimized is the Helmholtz free energy F = U TS

If (T, p) are constant, the energy minimized is the Gibbs free energy G = U + pV - TS





Statistical thermodynamics



$$S = k \log W$$

W - number of *microstates* for a given *macrostate*

This is "only" a postulate - but it works!

Why it should work: (i) in equilibrium $W \rightarrow \max$, so that $S \rightarrow \max$; (ii) S is additive, but W is multiplicative

Statistical thermodynamics

Let us consider a system that can be in one of states i with energy E_i

At a given *T*, the probability of the system to be in state *i* is $P_i = \frac{e^{-E_i/kT}}{Z}$, $Z = \sum_i e^{-E_i/kT}$, $\sum_i P_i = 1$

Ergodic hypothesis: average over time is equal to the average over ensemble - holds if all states are equiprobable (for most realistic systems)

What are the values of entropy and thermodynamic potentials?

Statistical thermodynamics

Consider the ensemble of *N* replicas of the system - let us count microstates of this ensemble

A microstate describes which replicas are in which state, while a macrostate describes how many replicas are in each state; thus: $W = \frac{N!}{N_1!(N-N_1)!} \frac{(N-N_1)!}{N_2!(N-N_1-N_2)!} \dots = \frac{N!}{N_1!N_2!\dots}$ where N_1 , N_2 ,... are the numbers of the replicas in state 1, 2,...

 $N_i = NP_i = N \frac{e^{-E_i/kT}}{Z}, \tilde{S} = k \ln W = k \ln(N!) - k \sum_i \ln(N_i!)$ Z - canonical partition function Use Stirling's formula: $\ln(N!) \approx N \ln N - N$

Statistical thermodynamics $\tilde{S} = k \ln W = N k \ln Z + \frac{N}{TT} \sum_{i} E_{i} e^{-E_{i}/kT}$ Internal energy, by definition: $\widetilde{U} = \frac{N}{z} \sum_{i} E_{i} e^{-E_{i}/kT} = \frac{NkT^{2}}{z} \frac{\partial Z}{\partial T}$ $U = \frac{\widetilde{U}}{N} = \frac{kT^2}{Z} \frac{\partial Z}{\partial T} = kT^2 \frac{\partial \ln Z}{\partial T}$ $S = \frac{\tilde{S}}{N} = \frac{k \ln W}{N} = k \ln Z + \frac{U}{T} = k \ln Z + kT \frac{\partial \ln Z}{\partial T}$ $F = U - TS = -kT \ln Z$ $G = F + pV = -kT\ln Z + pV$ $\mu(T,p) = \left(\frac{\partial G}{\partial N_p}\right)_{T,p} = \frac{\partial}{\partial N} (-kT \ln Z + pV)_{T,p}$

Statistical thermodynamics

Practical example: surface free energy



Change in Gibbs free energy upon addition of O to the surface: $\Delta G = G_{surf}(N_0 + 1) - (G_{surf}(N_0) + \frac{1}{2}\mu_{O_2})$ since $\mu_0 = \frac{1}{2}\mu_{O_2}$ Goal - find surface composition and structure that minimizes *G* at given *T*, *p*

Statistical thermodynamics

Practical example: surface free energy

 $\Delta \gamma(N_0, T, p) = \frac{1}{A} \left[G_{surf}(N_0, T, p) - G_{surf}(N_0^{ref}, T, p) - \mu_0 \left(N_0 - N_0^{ref} \right) \right] \rightarrow \min_{N_0}$

where A is the surface area, N_0^{ref} is the number of O atoms in the reference system

$$G_{surf}(N_0) - G_{surf}(N_0^{ref}) = \Delta E_{surf} + \Delta U_{vib} - T\Delta S_{vib} - T\Delta S_{conf} + p\Delta V$$
$$\mu_0(T,p) - ?$$

Statistical thermodynamics

Let us consider a gas of *N* non-interacting diatomic (for simplicity) molecules

Each molecule has the following degrees of freedom: nuclear, electronic, *translational*, rotational, vibrational

$$Z = \frac{(z_{transl})^N}{N!} (z_{rot})^N (z_{vib})^N (z_{el})^N (z_{nucl})^N$$

translational states are invariant with respect to any permutations of molecules (indistinguishable molecules)

 z_x - partition function for the degree of freedom x for a single molecule

Statistical thermodynamics $\mu(T,p) = \frac{\partial}{\partial N} (-NkT \ln(z_{transl}) + kT \ln N! - NkT \ln(z_{rot}) - NkT \ln(z_{rot})) + kT \ln N! - NkT \ln(z_{rot}) - NkT \ln(z_{rot}) + kT \ln N! - NkT \ln(z_{rot}) - NkT \ln(z_{rot}) + kT \ln N! - NkT \ln(z_{rot}) - NkT \ln(z_{rot}) + kT \ln N! - NkT \ln(z_{rot}) - NkT \ln(z_{rot}) + Nk$

Remember ideal gas law pV = NkT and Stirling's formula

$$\mu(T,p) = -kT \ln\left(\frac{z_{transl}}{N}\right) - kT \ln(z_{rot}) - kT \ln(z_{vib}) - kT \ln(z_{el}) - kT \ln(z_{nucl}) + kT$$

$$\frac{z_{transl}}{N} = \frac{V}{N} \int e^{-\frac{\hbar \mathbf{k}^2}{2mkT}} d^3 \mathbf{k} = \frac{V}{N} \left(\frac{2\pi mkT}{\hbar^2}\right)^{\frac{3}{2}} = \frac{kT}{p} \left(\frac{2\pi mkT}{\hbar^2}\right)^{\frac{3}{2}}$$

required input - molecule's mass m $z_{el} = \sum_{i} (2s_i + 1)e^{-\frac{E_i}{kT}} \approx (2s_0 + 1)e^{-\frac{E_0}{kT}} \rightarrow \mu_{el} \approx E_0 - kT \ln(2s_0 + 1)$ required input - E_0 , s_0

Statistical thermodynamics

$$z_{rot} = \frac{1}{\sigma} \sum_{J} (2J+1) e^{-\frac{B_0 J (J+1)}{kT}} \approx \frac{1}{\sigma} \int_0^\infty (2J+1) e^{-\frac{B_0 J (J+1)}{kT}} dJ = \frac{T}{\sigma \theta_r}$$

where $\sigma = 2$ for homonuclear molecules (indistinguishable with respect to permutation of the two identical nuclei), $\sigma = 1$ for heteronuclear molecules,

$$\theta_r = \frac{\hbar^2}{2kI}$$
, $I = \frac{m_A m_B}{m_A + m_B} d^2$, d is the bond length

 $\mu_{rot} \approx -kT \ln\left(\frac{2kTI}{\sigma\hbar^2}\right)$, required input - rotational constant $B_0 = \frac{\hbar^2}{2I}$ (calculated or from microwave spectroscopy)

Statistical thermodynamics

$$z_{vib} = \prod_{i=1}^{M} \sum_{n=0}^{\infty} e^{-(n+\frac{1}{2})\frac{\hbar\omega_i}{kT}} = \prod_{i=1}^{M} e^{-\frac{\hbar\omega_i}{2kT}} \sum_{n=1}^{\infty} e^{-\frac{n\hbar\omega_i}{kT}} =$$

$$= \prod_{i=1}^{M} \frac{e^{-\frac{\hbar\omega_i}{2kT}}}{1-e^{-\frac{\hbar\omega_i}{kT}}}$$
 (used the fact that sum over *n* is a geometric series)

For a diatomic molecule $\mu_{vib} = \frac{\hbar\omega}{2} + kT \ln(1 - e^{-\hbar\omega/kT})$ required input - vibrational frequency ω

In most practical cases, we can neglect the interaction between nuclear spins, so that $z_{nucl} \approx 1$ (not correct at very low temperatures)

□ Ab initio atomistic thermodynamics

It is convenient to define a reference for $\mu(T, p)$: $\mu(T, p) = E_0 + \Delta \mu(T, p)$



Alternatively: $\Delta \mu(T, p) = \Delta \mu(T, p^{o}) + k_{B}T \ln(p/p^{o})$ and $\Delta \mu(T, p^{o} = 1 \text{ atm})$ from thermochemical tables (e.g., JANAF)



□ Ab initio atomistic thermodynamics



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Example: Metal surface in contact with O₂ gas



bulk Pd metal

Reservoir: $\mu_0(T, p_{O_2})$ from ideal gas, $N_0^{ref} = 0$ (bare metal surface is the reference system), $\frac{1}{2}E_{O_2}$ is the reference for the chemical potential of O: $\mu_0 = \Delta \mu_0 + \frac{1}{2}E_{O_2}$

Neglect for now
$$\Delta F_{vib}$$
 and $T\Delta S_{conf}$
$$\Delta \gamma(T, p_{O_2}) = \frac{1}{A} \left[E_{surf}(N_O) - E_{surf}(0) - N_O \frac{1}{2} E_{O_2} \right] - \frac{1}{A} N_O \Delta \mu_O(T, p_{O_2})$$



First-principles atomistic thermodynamics: constrained equilibria



C.M. Weinert and M. Scheffler, Mater. Sci. Forum 10-12, 25 (1986); E. Kaxiras *et al.*, Phys. Rev. B 35, 9625 (1987); K. Reuter and M. Scheffler, Phys. Rev. B 65, 035406 (2001); Phys. Rev. B 68. 045407 (2003)





M. Valtiner, M. Todorova, G. Grundmeier, and J. Neugebauer, PRL 103, 065502 (2009)

When vibrations do matter



M. Valtiner, M. Todorova, G. Grundmeier, and J. Neugebauer, PRL 103, 065502 (2009)

Thermodynamics of Defects

Very small concentrations of defects can significantly alter materials properties



Small concentration of Fe impurities are visible by naked eye in intrinsically transparent MgO

Si semiconductors contain 10⁻⁹-10⁻³ intentional impurities per atom

"My precious!": Perfect defected gems



Impurities are responsible for the color of sapphire and many other precious stones

Typical concentrations: 100-10000 ppm

Fe,Ti:Al₂O₃

Entropy

$$G = U + pV - TS$$



$$S = k \ln W$$

W – number of microstates

- 1) Solid: vibrational entropy (phonons)
- 2) Solid: electronic entropy
- 3) Gas: vibrational, rotational, translational, etc. (part of μ_i)
- 4) Solid: defect disorder

Configurational entropy

$$G = [U + pV - T(S - S_{\text{config}})] - TS_{\text{config}} = \widetilde{G} - TS_{\text{config}}$$

$$N \text{ equivalent defect sites in the sold}$$

$$n \text{ defects}$$
If defects do not interact:
$$S_{\text{config}} = k \ln \frac{N!}{n!(N-n)!}$$

Stirling's formula:

$$\ln(n!) = n(\ln n - 1 + \delta), \ n >> 1, \ \delta \sim \frac{\ln(2\pi n)}{2n}$$

$$S_{\text{config}} \approx k \left[N \ln N - n \ln n - (N - n) \ln (N - n) \right]$$

Good approximation only on a macroscopic scale

Defect concentration

Minimize the free energy of the system with respect to the number of defects



 $G(n) = \tilde{G}_0 + n\Delta G_f - TS_{\text{config}}(n)$

If defects do not interact:

$$\frac{n}{N} = \frac{1}{\exp(\Delta G_f / kT) + 1}$$

Vacancy concentration

$$\frac{n}{N} << 1 \Leftrightarrow \exp(\Delta G_f / kT) >> 1$$

 $\frac{n}{N} \approx \exp\left(-\Delta G_f(T,p)/kT\right)$ – textbook formula

$$\frac{n}{N} = \frac{1}{\exp(\Delta G_f / kT) + 1}$$

for non-interacting defects

But can charged defects be considered as non-interacting?!





For a system of charges:



$$V_{\text{interact}} = \frac{1}{2} \sum_{i \neq j} \frac{Q_i Q_j}{|r_i - r_j|}$$

In the thermodynamic limit $(N \rightarrow \infty)$ the electrostatic energy of charges with any finite concentration *diverges*

Charged defects *must be compensated* in realistic materials

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Typical dependence of the defect formation energy as a function of unit cell size



Typical dependence of the defect formation energy as a function of unit cell size

In standard periodic calculations the charge per unit cell is compensated by a uniform background charge (occurs naturally as a regularization of the Ewald summation)

The compensated defects interact much weaker with each other

But they do interact strongly with the compensating charge (~1/L)

Local and global effects of doping

In realistic semiconductors, charged defects can be compensated by the *depletion* of charge carriers (electrons or holes)



Local effect of doping (chemical bond formation, local relaxation) electrons occupying hole states (localized or not)



Global effect of doping (interaction with the compensating charge)

Formation energy and concentration of charged defects depend strongly on the distribution of the defects and the compensating charge

Charged defects in a doped material

$$\Delta G(n) = n\Delta G_f(n \to 0) + \frac{1}{2} \varepsilon_0 \int \varepsilon(\mathbf{r}) |\mathbf{E}|^2 d^3 r - TS_{\text{config}}(n)$$
formation energy
in the dilute limit
electrostatic energy
at finite n

$$S_{\text{config}} = k \ln Z + \frac{U}{T}$$

The charged defects are screened by the compensating charge:

$$S_{\text{config}} \approx k \ln \frac{N!}{n!(N-n)!}$$

Space charge formation and band bending



Space charge region $z_{SC} = \sigma/eN_D$ causes band bending and electric field N_D -- dopant concentration

 σ -- surface charge due to charged vacancies

Band bending

 $\Delta G_{\rm f}^{\rm VCA}(\sigma,d) = E_{\rm vac}^q(\sigma,d)(+q\varepsilon_{\rm VBM}) - E_{\rm host}(\sigma,d) + \frac{1}{2}E_{\rm O_2}$



Band bending

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Sampling configurations

Coarse-graining potential-energy surface (PES)



Sampling configurations: cluster expansion

Coarse-graining potential-energy surface (PES)



Phase transformation in an alloy or adsorbate layer at a surface

Summary

- Ab initio atomistic thermodynamics approach allows to model materials in thermodynamic equilibrium at realistic temperatures and pressures from first principles
- Surface phase diagrams and defect concentrations as a function of temperature and pressure are two prominant examples
- Doping should be considered as a thermodynamic variable, along with temperature and pressure

The End ...